CLAIMS:

1. A method comprising the steps of:

providing a substrate having a location thereon defining an imprint field having a border, the imprint field further defined by an interior region and a perimeter region surrounding the interior region, wherein the perimeter region further includes fluid control features in the substrate;

depositing a polymerizable material onto the substrate at the imprint field location; and

allowing the polymerizable material to spread on the substrate, wherein the fluid control features redirect the spreading of the polymerizable material so as to redirect the spreading of the polymerizable material away from the imprint field border.

2. The method of claim 1 wherein the imprint field border has one or more edges and wherein the fluid control features adjacent each such edge are directionally oriented parallel to such edge.

3. The method of claim 1 or 2 wherein the fluid control features further comprise elongated features having a length that is at least 10 or 100 or 1,000 or 10,000 times greater than their width.

4. The method of any one of the above claims wherein the fluid control features further comprise lines, line segments, or staggered bars.

5. The method of any one of the above claims further comprising the step of contacting an imprint lithography template having a pattern surface with a relief pattern located thereon with the polymerizable material on the substrate so as to fill the relief pattern of the template and wherein the imprint lithography template includes fluid control features in a region that aligns with the perimeter region.

6. The method of claim 5 wherein the fluid control features of the template are complementary to and aligned with or staggered relative to the fluid control features of the substrate.

7. The method of claim 5 further comprising the steps of solidifying the polymerizable material to form a patterned layer on the substrate at the imprint field location and separating the template from the formed patterned layer.

8. A method of manufacturing a device comprising:

forming a patterned layer on the substrate in accordance with the method of claim 7;

transferring a pattern of the patterned layer into the substrate; and

processing the substrate to manufacture the device.

9. A substrate having a location thereon defining an imprint field having a border, the imprint field further defined by an interior region and a perimeter region surrounding the interior region, wherein the perimeter region further includes fluid control features in the substrate.

10. The substrate of claim 9 wherein the imprint field border has one or more edges and wherein the fluid control features adjacent each such edge are directionally oriented parallel to such edge.

11. The substrate of claim 9 wherein the fluid control features further comprise elongated features having a length that is at least 10 or 100 or 1,000 or 10,000 times greater than their width.

12. The substrate of claim 9 wherein the fluid control features further comprise lines, line segments, or staggered bars.